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Oral presentation | 16 Amorphous and Microcrystalline Materials | 16.3 Bulk, thin-film and other silicon-based solar cells

## [5a-A204-1~11]16.3 Bulk, thin-film and other silicon-based solar cells

Katsuhiko Shirasawa(AIST)

Tue. Sep 5, 2017 9:00 AM - 12:00 PM A204 (204)

△：奨励賞エントリー

▲：英語発表

▼：奨励賞エントリーかつ英語発表

空欄：どちらもなし

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11:45 AM - 12:00 PM

## [5a-A204-11][JSAP Young Scientist Award Speech] Influence of substrate temperature on the properties of i-a-Si:H passivation layer deposited by facing target sputtering

○Yuta Shiratori<sup>1</sup>, Akira Faris<sup>1</sup>, Kazuyoshi Nakada<sup>1</sup>, Shinsuke Miyajima<sup>1</sup> (1.Tokyo Tech.)

Keywords:crystalline Si solar cell, passivation layer